



(51) International Patent Classification:

A61M 1/00 (2006.01) A43B 13/40 (2006.01)

(21) International Application Number:

PCT/US2009/037076

(22) International Filing Date:

13 March 2009 (13.03.2009)

(25) Filing Language:

English

(26) Publication Language:

English

(30) Priority Data:

61/036,433 13 March 2008 (13.03.2008) US

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(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM,

AO, AT, AU, AZ, BA, BB, BG, BH, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RS, RU, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MK, MT, NL, NO, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

- with international search report (Art. 21(3))
- before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments (Rule 48.2(h))

(54) Title: OFFLOADING AND REDUCED-PRESSURE TREATMENT SYSTEMS AND METHODS

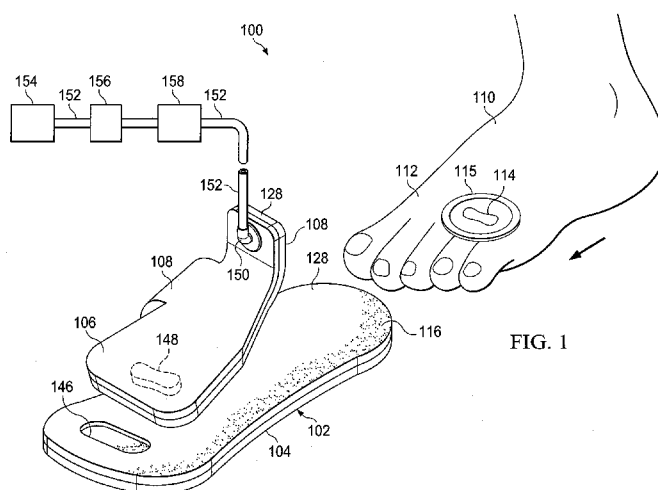


FIG. 1

(57) Abstract: An offloading and reduced-pressure treatment system (100) includes an offloading and reduced-pressure treatment device (102), which has a plantar member (104) formed from an offloading manifold material. The offloading and reduced-pressure treatment system further includes a reduced-pressure interface (150) fluidly coupled to the pressure-transmitting layer of the plantar member, a reduced-pressure source (154), and a reduced-pressure delivery conduit (152) fluidly coupled to the reduced-pressure source and to the offloading and reduced-pressure treatment device. The offloading manifold material includes a first barrier layer, a support layer (128), a pressure-transmitting layer and a second barrier layer. The offloading and reduced-pressure treatment device may also have a dorsal member (106) and a bridge member (108). Methods are also presented.

